	Application No.	Applicant(s)	
Notice of Allowability	10/616,983	NAITOU ET AL.	(-) /
	Examiner	Art Unit	
	John A. McPherson	1756	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	b (OR REMAINS) CLOSED in this apply or other appropriate communication is subject to and MPEP 1308.	correspondence addi	ded
1. This communication is responsive to the IDS filed 12/3/03.			
2. The allowed claim(s) is/are 1-5.			
3. Acknowledgment is made at a slaim for the by	xaminer.		
4. ⊠ Acknowledgment is made of a claim for foreign priority un a) ⊠ All b) ☐ Some* c) ☐ None of the:			
1. 🛛 Certified copies of the priority documents have	e been received.		
2. Certified copies of the priority documents have	e been received in Application No	<u> </u>	
3. Copies of the certified copies of the priority do	cuments have been received in this i	national stage applica	ition from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:  5. Acknowledgment is made of a claim for democtic priority.	1 0511000011111111111111111111111111111		
5. Acknowledgment is made of a claim for domestic priority un reference was included in the first sentence of the specifical	nder 35 U.S.C. § 119(e) (to a provision of the standard of the	onal application) since	e a specific
(a) ☐ The translation of the foreign language provisional a	pplication has been received		
<ol> <li>Acknowledgment is made of a claim for domestic priority unin the first sentence of the specification or in an Application</li> </ol>	nder 35 U.S.C. §§ 120 and/or 121 sir Data Sheet. 37 CFR 1.78.		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of the second o	this application. THIS THREE-MON	ITH PERIOD IS NOT	EXTENDABLE
7. A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give	es reason(s) wny the oath or declarat	S AMENDMENT or Ni ion is deficient.	OTICE OF
8. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperson 1) hereto or 2) to Paper No.	t be submitted. on's Patent Drawing Review ( PTO-9	348) attached	
(b) ☐ including changes required by the proposed drawing co	arrection filed which has been	- Out of	
(c) ☐ including changes required by the attached Examiner's	Amendment / Comment or in the Of	n approved by the ⊨x fice action of Paper N	(aminer. lo
Identifying indicia such as the application number (see 37 CFR 1.8 each sheet. Replacement sheet(s) should be labeled as such in th	84(c)) should be written on the drawing e margin according to 37 CFR 1.121(d)	js in the front (not the ).	back) of
9. DEPOSIT OF and/or INFORMATION about the depos attached Examiner's comment regarding REQUIREMENT FOR THE	iit of BIOLOGICAL MATERIAL m HE DEPOSIT OF BIOLOGICAL MAT	ust be submitted. N ERIAL.	ote the
Attachment(s)			
1⊠ Notice of References Cited (PTO-892)	5 Notice of Informat Date	ant August 11 (DTO	4 = 0.
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No	5⊡ Notice of Informal Pate 6⊡ Interview Summary (P		
	7 Examiner's Amendmer		·
4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8⊠ Examiner's Statement 9⊡ Other		ance

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## Pertinent Prior Art

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

US 2002/0172492 discloses photodefinable silsesquioxane compositions and method of forming optical waveguides using the compositions, wherein the composition may include a photobase generator, for example 4-(ortho-nitrophenyl)dihydropyridines. The methods comprise exposing the composition to actinic radiation so as to render the exposed areas less soluble than the unexposed areas.

US 5,292,620 discloses a method of making an optical waveguide comprising the steps of exposing to light a region of a substantially dry photohardenable film adhered to a support, then laminating a substantially first dry photohardenable layer which is adhered to a support to one side of the film, removing the support, then laminating a second substantially dry photohardenable layer which is adhered to a support to the other side of the film, and hardening the layers and the film.

## Allowable Subject Matter

The following is an examiner's statement of reasons for allowance:

In a process of producing a polymer optical waveguide comprising the steps of forming an undercladding layer on a substrate, forming a photosensitive resin composition layer containing a 1,4-dihydropyridine derivative and a resin on the undercladding layer, irradiating a region of the photosensitive resin composition layer corresponding to a core portion pattern with UV light through a mask to form UV light-

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exposed areas and UV light-unexposed areas on the photosensitive resin composition layer, a step of heating the UV light-exposed areas of the photosensitive resin composition layer, and a step of forming an overcladding layer on the photosensitive resin composition layer after heating, the prior art does not teach or suggest the process wherein the heating step further comprises heating the UV light-unexposed areas of the photosensitive resin composition layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John A. McPherson whose telephone number is (571) 272-1386. The examiner can normally be reached on Monday through Friday, 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on (571) 272-1385. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

John A. McPherson Primary Examiner Art Unit 1756

JAM 1/12/04